

WEST Search History

DATE: Sunday, September 26, 2004

Hide?	Set Name	Query	Hit Count
<i>DB=PGPB,USPT,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=OR</i>			
<input type="checkbox"/>	L31	l29 and l3	0
<input type="checkbox"/>	L30	L29 and l2	0
<input type="checkbox"/>	L29	irradia\$4	474512
<input type="checkbox"/>	L28	l2 and l22	0
<input type="checkbox"/>	L27	l26 and l21	35
<input type="checkbox"/>	L26	l22 same l24	2265
<input type="checkbox"/>	L25	l24 same l22	2265
<input type="checkbox"/>	L24	deposit\$5	1087600
<input type="checkbox"/>	L23	l21 and l22	165
<input type="checkbox"/>	L22	mix\$5 same irradiat\$5	42623
<input type="checkbox"/>	L21	(organic adj light)or oled\$	8678
<i>DB=USPT; PLUR=YES; OP=OR</i>			
<input type="checkbox"/>	L20	4539507.pn.	1
<input type="checkbox"/>	L19	4539507.pn.	1
<input type="checkbox"/>	L18	4720432.pn.	1
<input type="checkbox"/>	L17	4720432.pn.	1
<input type="checkbox"/>	L16	4769292.pn.	1
<input type="checkbox"/>	L15	4769292.pn.	1
<input type="checkbox"/>	L14	4885211.pn.	1
<input type="checkbox"/>	L13	4885211.pn.	1
<input type="checkbox"/>	L12	5672938.pn.	1
<input type="checkbox"/>	L11	5672938.pn.	1
<input type="checkbox"/>	L10	5672938.pn.	1
<input type="checkbox"/>	L9	5672938.pn.	1
<input type="checkbox"/>	L8	6016033.pn.	1
<input type="checkbox"/>	L7	6016033.pn.	1
<input type="checkbox"/>	L6	6307317.pn.	1
<input type="checkbox"/>	L5	6307317.pn.	1
<input type="checkbox"/>	L4	6392339.pn.	1
<input type="checkbox"/>	L3	6392339.pn.	1
<input type="checkbox"/>	L2	6392339.pn.	1

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Entry 1 of 1

File: PGPB

Jan 16, 2003

[Logout](#)DOCUMENT-IDENTIFIER: US 20030010288 A1

TITLE: Film formation apparatus and film formation method

Pre-Grant Publication (PGPub) Document Number:20030010288Summary of Invention Paragraph:

[0020] First, the substrate having the anode is loaded to a loading chamber. The substrate is transferred to an ultraviolet ray irradiation chamber via a first transferring chamber and ultraviolet irradiation is performed in a vacuum atmosphere to clean the surface of the anode. Note that, when the anode is an oxide such as ITO, oxidation processing is performed in a pretreatment chamber.

Summary of Invention Paragraph:

[0080] Therefore, light sources 211 for irradiating light are provided in the film formation chamber 210 to irradiate the organic compound molecules with light. The organic compounds to which the energy is applied by light irradiation are activated. Note that infrared light, ultraviolet light, or visible light is irradiated from the light sources 211. In view of preventing damage to the organic compound molecules, infrared light is preferable.

Summary of Invention Paragraph:

[0081] The residence time of the organic compound molecules on the surface of the substrate is extended by light irradiation and the organic compound molecules can be easily formed into a film in an optimum position on the substrate. Thus, a denser film can be formed.

Summary of Invention Paragraph:

[0082] FIG. 3A shows a structure of the organic compound film formed by ordinary film formation process and FIG. 3B shows a structure of the organic compound film in the case where the organic compound film is irradiated with light in the molecular activation region 213.

Summary of Invention Paragraph:

[0083] With respect to the respective structures, an anode is formed on a substrate, a first functional region 221, a first mixed region 222, and a second functional region 223 are formed thereon, and finally a cathode is formed thereon. Thus, light emitting elements with such structures are obtained. According to the element shown in FIG. 3B, a distance between the organic compound molecules becomes short and thus a denser film is formed, as compared with the element shown in FIG. 3A. Note that, when gaps are produced between the organic compound molecules in the inner portion of the organic compound film as shown in FIG. 3A, they become defects and movement of carriers is hindered in the defect portions. Thus, the reduction in luminance and the deterioration in an element are caused by the storage of charges. Therefore, it is effective to provide the light sources in the film formation chamber and light irradiation is performed at film formation.

Detail Description Paragraph:

(FILE 'HOME' ENTERED AT 11:14:47 ON 26 SEP 2004)

FILE 'INSPEC' ENTERED AT 11:14:56 ON 26 SEP 2004

L1 15264 ORGANIC (P) DEPOSIT#####
L2 116579 IRRADIAT#####
L3 579250 4
L4 116579 IRRADIAT#####
L5 518 L1 (P)L4
L6 0 CAHMBER
L7 44649 CHAMBER
L8 10 L5(P)L7
L9 15 DHIS
L10 90 FIRST (A) ORGAN####
L11 46 SECOND(A) ORGAN####
L12 0 L5 AND L10 AND L11
L13 0 L10 AND L11 AND L4

FILE 'CA' ENTERED AT 11:27:44 ON 26 SEP 2004

L14 2227 DEPOSITION(A) CHAMBER
L15 0 L5 AND L14
L16 45 L2 AND L14

FILE 'INSPEC' ENTERED AT 11:42:01 ON 26 SEP 2004

L17 9 L16

FILE 'CA' ENTERED AT 11:44:17 ON 26 SEP 2004

L18 32 L1 AND L2

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<u>Hide?</u>	<u>Set Name</u>	<u>Query</u>	<u>Hit Count</u>
		<i>DB=PGPB,USPT,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=OR</i>	
<input type="checkbox"/>	L14	L13 and l11	1
<input type="checkbox"/>	L13	20030010288	2
<input type="checkbox"/>	L12	L11 and l10	13
<input type="checkbox"/>	L11	irradi\$5	474707
<input type="checkbox"/>	L10	L9 and l5	69
<input type="checkbox"/>	L9	L8 or l7	8678
<input type="checkbox"/>	L8	organic adj light	7700
<input type="checkbox"/>	L7	oled\$	4323
<input type="checkbox"/>	L6	L5 same irradiat\$4	5
<input type="checkbox"/>	L5	L4 same l3	230
<input type="checkbox"/>	L4	deposit\$5	1087600
<input type="checkbox"/>	L3	l1 same l2	1887
<input type="checkbox"/>	L2	second adj organ\$3	4123
<input type="checkbox"/>	L1	first adj organ\$2	3973

END OF SEARCH HISTORY